



Serial No. 09/914,204  
Docket No. WLJ.075  
Response filed June 13, 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of	:	<b><u>Mail Stop Amendment</u></b>
John MACNEIL et al.	:	Group Art Unit: 1762
Serial No. 09/914,204	:	Examiner: Elena Tsoy
Filed February 20, 2002	:	

# A METHOD OF PROCESSING A POLYMER LAYER

## REQUEST FOR RECONSIDERATION

U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop Amendment  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314

Sir:

This is in response to the Office Action dated February 11, 2005.

Initially, Applicants wish to thank the Examiner for the courtesy of granting the personal interview which took place at the U.S. Patent and Trademark Office on May 20, 2005.

During the interview, the Examiner agreed to withdraw all the rejections of record, and accordingly, Applicants respectfully request reconsideration of the rejections under 35 U.S.C. 102 and 103. Also, Applicants presently intend to file a Terminal Disclaimer to obviate the double patenting rejection when the application is otherwise in condition for allowance.

Respectfully submitted,

JOHN MACNEIL ET AL.

A handwritten signature in black ink, appearing to read 'Adam C. Volentine', with a long horizontal stroke extending to the right.

Adam C. Volentine  
Registration No. 33289

June 13, 2005

Volentine Francos & Whitt, P.L.L.C.  
11951 Freedom Drive, Suite 1260  
Reston, VA 20190  
Tel. (703) 715-0870  
Fax (703) 715-0877